

Demonstration of advanced oxidation technology

UV/H₂O₂ processes

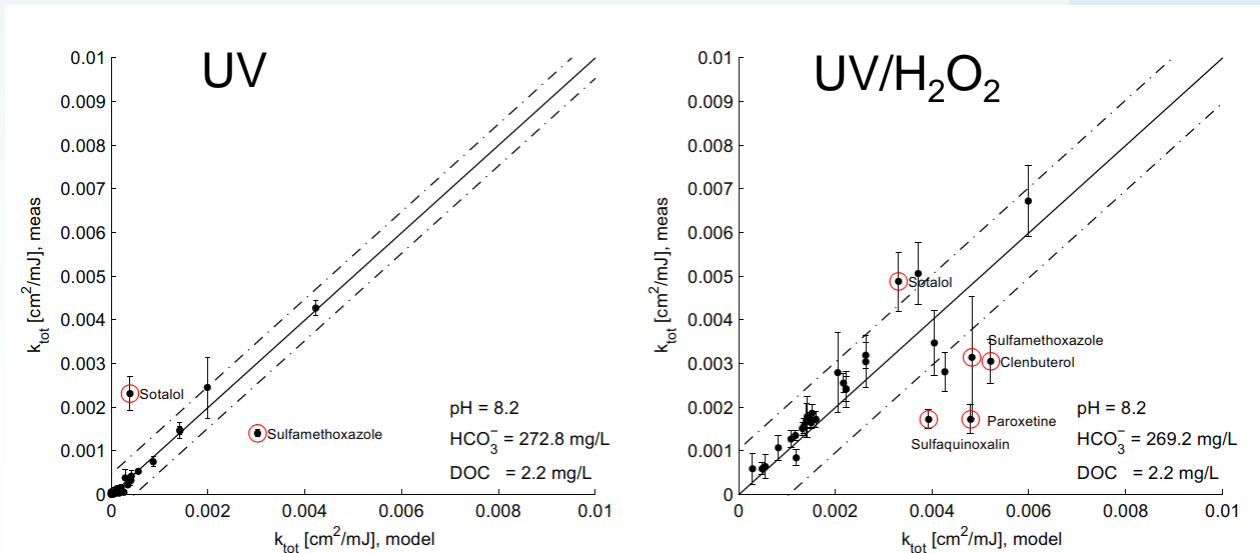
Dunea and WML



Previous project (KWR, Wetsus, van Remmen, BTO):

- Kinetic model
conversion of compounds as a function of UV dose
- CFD model
UV dose distribution in reactor
- Combined model: conversion prediction in UV reactor

Accurate predictions by model for LP UV reactor, taking into account: CO_3^{2-} and HCO_3^- , NO_3^- , NOM, temperature

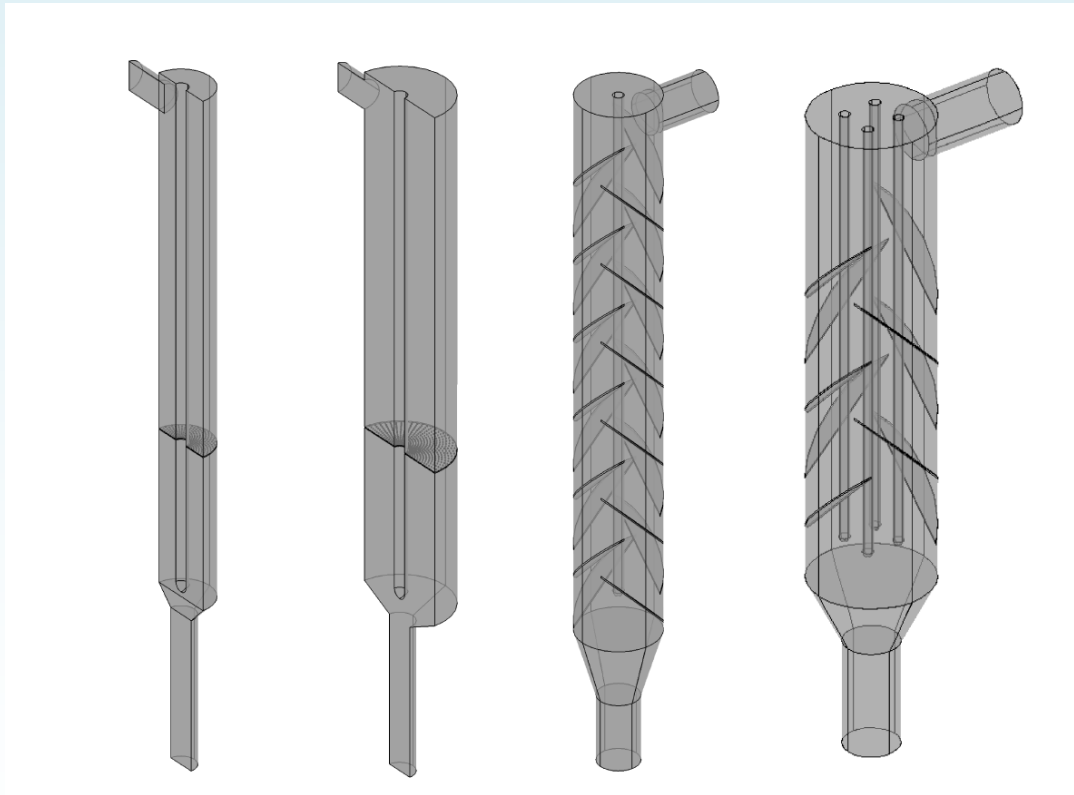


Model can be used to:

- Predict conversion of micropollutants in UV/H₂O₂ reactor
- Optimize geometry of UV/H₂O₂ reactor

Number of lamps, position of lamps, water layer thickness, etc.

Optimization of reactor geometry



Various types of reactors, differing in geometry

Dunea: 3 reactors

D200: optimized disinfection reactor (1 flow plate)

one 120 W LP UV lamp

1 m³/h

Prediction: energy demand 20-30% lower

NEW: optimized by means of CFD for

UV-T 85-90%: additional 5-15% energy

savings predicted

four 300 W LP UV lamps

10 m³/h

Dunea: 3 reactors

CHAOS: design by van Remmen
ten 120 W LP UV lamps
10 m³/h

35-40 pharmaceuticals, pCBA and atrazine
Effect water matrix determined in CB

Dunea: 3 reactors

Effect of water matrix:

Pretreatment by means of ACF or O_3/H_2O_2

Improvement in log degradation: 30-70%

ACF more efficient:

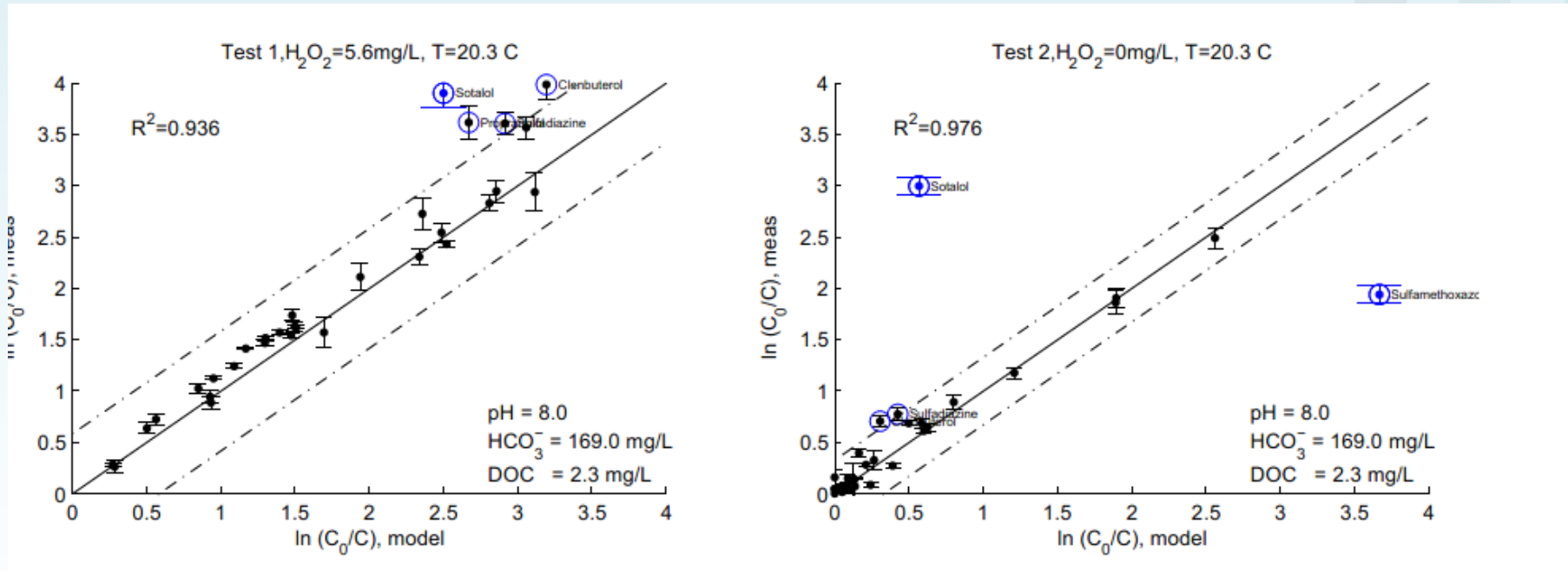
- higher UV-T increase
- DOC decreased

Dunea: 3 reactors

Efficiency increase:

- D200: 20-40% compared with disinfection reactor
- NEW: 5-10% compared with D200 for high UV-T (lower efficiency at lower UV-T) for all compounds
- CHAOS: 5-10% lower compared with D200. Higher mean UV-dose beneficial for some compounds. Compounds with high removal rate less efficient, due to high sensitivity towards UV dose distribution

Modelling of NEW reactor: good accordance



WML

D200 with 2 flow plates

First series: much higher conversion than predicted
(average 92%)

Explanations:

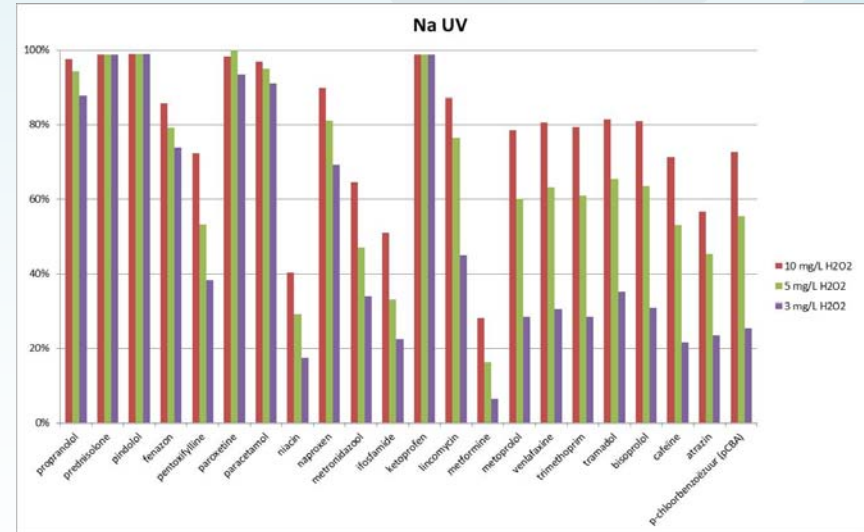
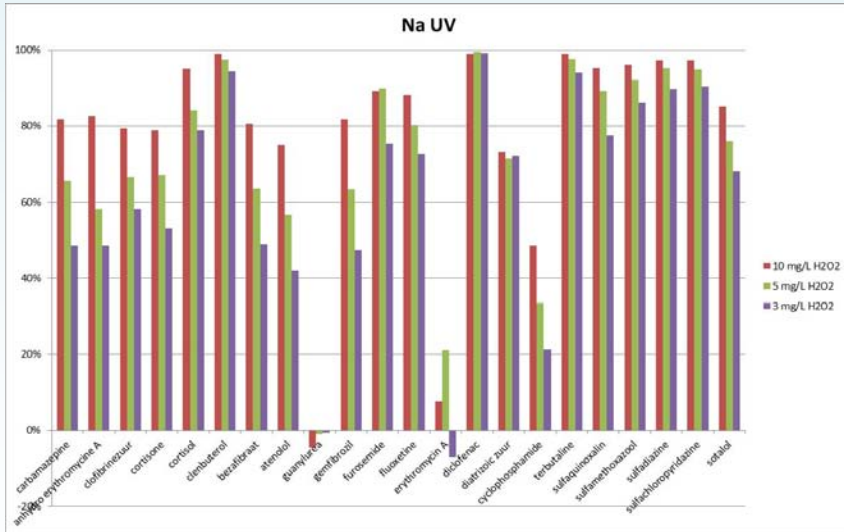
- high UV-T (93%), increased UV dose by reflection at reactor wall
- Increase of UV-T during experiment
- two flow plates in stead of one.

Demonstration at WML

Lamp power 80%, increased flow

Flow (m ³ /hour)	UV dose (mJ/cm ²)	Predicted conversion (%)	Measured conversion (%)
1	601	84	90
1,5	401	75	85
2	301	68	81

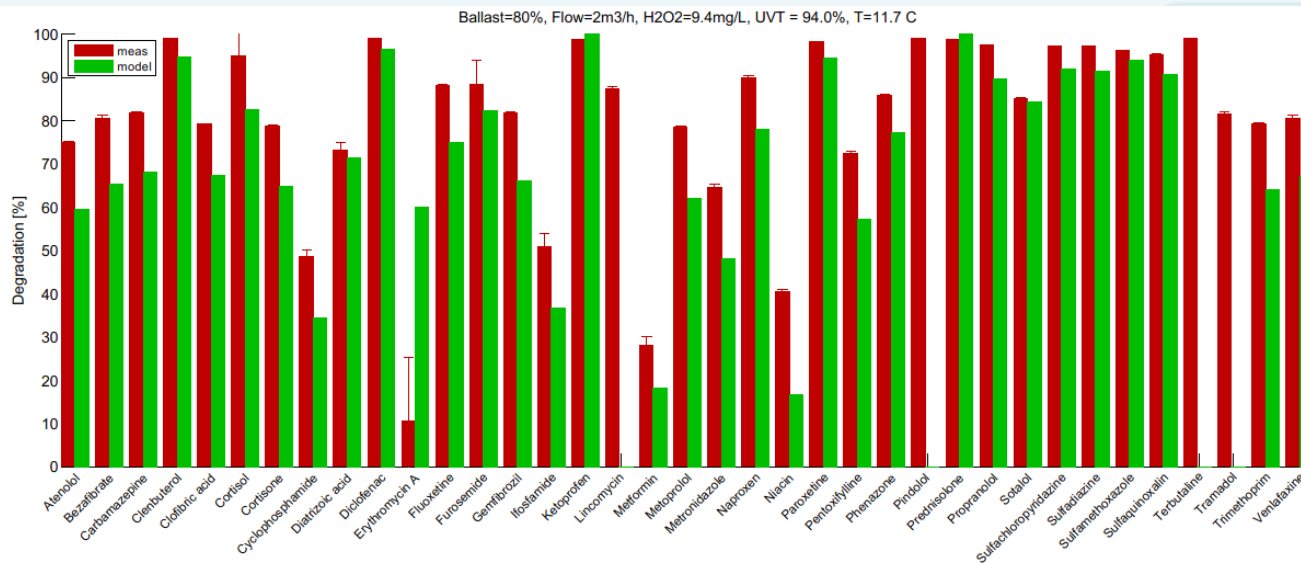
Demonstration at WML, lower H₂O₂ concentration (10, 5 and 3 mg/L)



WML: predicted versus measured

Modeling: UV-T = 94%, but increases

Good reproducibility Nov. 2014 vs. March 2015



WML: metabolites

- Metabolites may be present in pretreated water
- Metabolites and transformation products can be formed or degraded by H_2O_2 ;
- conversion in UV/ H_2O_2 process: more conversion at higher UV doses
- Lower H_2O_2 concentrations: more metabolites/transformation products

Optimization:

Conversion of target compounds AND formation and conversion of metabolites and transformation products.

WML: formation of mutagenic byproducts?

Expectation: no problem, LP UV lamp, low NO_3^- content.

In general low responses

- Sometimes positive response, but never in duplo: sample \neq mutagenic
- Positive response sometimes found in influent or in drinking water
- Responses are not increased by UV process

Operational Challenges

- How to implement AOP in an existing plant with UV for disinfection?
- Flexibility (modularity) required: optimal system setup and operation depending on (uncertain) future conditions (higher/extreme concentrations of OMP, as a result of climate change, demographic changes);
- What are decisive compounds, with (future) concentrations and standards, how does the complete system (reservoir, bank filtration) perform?
- Discussion precautionary principle versus curative solutions; AOP techniques may reduce intake stops;
- Focus wider than pharmaceuticals, pesticides bigger problem despite discharge WWTP upstream

Thank you for your attention!



University of Applied Sciences and Arts Northwestern Switzerland
School of Life Sciences

